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Supplementary Material: Polarization-Discriminated RSOA-EAM for Colorless Transmitter in WDM-PON

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10 1. Theoretical Models for the proposed PD RSOA-EAM

11 1.1 The optical model

12 The well-established traveling wave model [1,2] incorporating the signal and the broad-band 13 spontaneous emission noise, and the non-uniform carrier and photon distributions along the 14 waveguide is adopted to simulate the device's performance. The entire ASE spectrum is sliced into 15 N_d segments as described in [2]. The slowly varying forward and backward envelopes ($e_{TE,TM}^f$ and

16 $e_{TE,TM}^{b}$) of the signal and the sliced noise channels are governed by equations as follows:

19 where the subscripts TE and TM denote the TE and TM polarized electric fields, respectively. λ_k 20 (nm) is the wavelength of the *k*th (*k* =1,2, ..., *N*_d) channel in the sliced spectrum, α_H is the linewidth 21 enhancement factor, v_g (m/s) is the group velocity, Γ is the confinement factor, and α (cm⁻¹) is the 22 modal loss. $g_{TE,TM}$ (cm⁻¹) is the material gain of the TE/TM mode that depends on the position in the 23 cavity, the wavelength, and the time. $\tilde{s}_{TE,TM}^f$ and $\tilde{s}_{TE,TM}^b$ (V/m) are the forward and backward 24 spontaneous emission noise, respectively. The noise power contribution in a small section d_z along

25 the propagation direction can be phenomenologically evaluated as [2]:

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$$\frac{n_{eff}}{2} \sqrt{\frac{\varepsilon_0}{\mu_0}} \left| \tilde{s}_{TE,TM}^{f,b}(z,t) \right|^2 d_z^2 = \gamma R_{TE,TM}^{sp}(z,t,\lambda_k) h v_k(wd) d_z, \qquad (S2)$$

27 where n_{eff} is the effective refractive index, ε_0 (F/m) and μ_0 (H/m) are the permittivity and 28 permeability in a vacuum, respectively. γ is the coupling ratio of the spontaneous emission noise 29 into the waveguide, $R_{TE,TM}^{sp}$ (cm⁻³s⁻¹) is the spontaneous emission rate, hv_k (J) is the photon energy 30 of the *k*th wavelength channel, and *wd* (µm²) is the active region cross-sectional area. 31 As a Langevin noise source, the amplitude and phase of $\tilde{s}_{TE,TM}^{f,b}(z,t,\lambda_k)$ given in equation (S1) 32 and (S2) can be approximately modeled by the Gaussian and uniformly distributed random processes,

33 respectively. It's therefore expressed as:

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$$\sum_{TE,TM}^{S,f,b}(z,t) = \left(x_1 e^{ix_2}\right) \left| \tilde{S}_{TE,TM}^{f,b}(z,t) \right|,$$
(S3)

35 where x_1 follows the Gaussian distribution with zero mean and a self-covariance of one, and x_2 36 follows the uniformly random distribution over $[0, 2\pi]$.

37 1.2 The material gain/absorption model

The material gain dispersiveness in the compressively strained quantum well active region ofthe SOA can be well approximated by [3-5]:

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$$g_{TE}(z,t,\lambda_{k}) = \frac{g_{0}\ln(N(z,t)/N_{0})}{1 + \varepsilon_{s}\left[\sum_{k=1}^{N_{d}}\sum_{i=TE,TM}\left(S_{i}^{f}(z,t,\lambda_{k}) + S_{i}^{b}(z,t,\lambda_{k})\right)\right]}\left[1 - 2\left(\frac{\lambda_{k} - \lambda_{c}}{\lambda_{W}}\right)^{2}\right]$$
(S4)

41 with g_0 (cm⁻¹) denoting the gain coefficient, N_0 (cm⁻³) the transparent carrier density, ε_s (cm³) the 42 nonlinear gain suppression coefficient, λ_c (nm) the gain peak wavelength, and λ_W (nm) the full 43 width at half maximum. $S_{TE}^f(z,t,\lambda_k)$, $S_{TE}^b(z,t,\lambda_k)$, $S_{TM}^f(z,t,\lambda_k)$, and $S_{TM}^b(z,t,\lambda_k)$ (cm⁻³) are the 44 photon densities of the forward TE, backward TE, forward TM, and backward TM optical fields of 45 the *k*th wavelength channel, respectively. The TM material gain $g_{TM}(z,t,\lambda_k)$ is assumed to be zero 46 in the compressively strained quantum well.

47 The photon density distribution is calculated by:

$$S_{TE,TM}^{f,b}(z,t,\lambda_k) = \frac{n_{eff}}{2h\nu_k} \sqrt{\frac{\varepsilon_0}{\mu_0} \frac{\Gamma}{w d\nu_g}} \left| e_{TE,TM}^{f,b}(z,t,\lambda_k) \right|^2$$
(S5)

49 The spontaneous emission rate $R_{TE,TM}^{sp}$ in equation (S2) is related with the material gain through 50 [2,3]:

$$R_{TE,TM}^{sp}(z,t,\lambda_k) = \left(\frac{8\pi n_{eff}^2 \nu_k^2 \Delta \nu}{c^2}\right) n_{sp} g_{TE,TM}(z,t,\lambda_k)$$
(S6)

52 where Δv (Hz) is the frequency difference between the adjacent wavelength channels, *c* (m/s) is 53 the velocity of the light in a vacuum, and n_{sp} is the inversion factor relating the spontaneous 54 emission gain and the material gain [3].

55 The absorption in the EAM is assumed to be polarization and wavelength independent. A 56 phenomenological model [6] is used to calculate the EAM material absorption:

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$$g_{TE,TM}(z,t) = \alpha_{TE,TM}^{EAM}(z,t) = \frac{-a_V \left(V(z,t) - V_{on}\right)^2}{1 + P(z,t) / P_{sat}}$$
(S7)

58 where a_V (cm⁻¹V⁻²) is the absorption constant, *V* (V) is the driving voltage, V_{on} (V) is a reference 59 voltage, and P_{sat} (mW) is the saturation power of the EAM.

- 60 1.3 The carrier rate equation
- 61 The spatial and time dependent carrier density N(z,t) in the SOA can be solved by the following 62 rate equation:

$$63 \qquad \qquad \frac{\partial N(z,t)}{\partial t} = \frac{\eta_i I(z,t)}{eLwd} - \left[AN(z,t) + BN(z,t)^2 + CN(z,t)^3\right] \\ - v_g \sum_{k=1}^{N_d} \left\{ g_{TE}(z,t,\lambda_k) \left[S_{TE}^f(z,t,\lambda_k) + S_{TE}^b(z,t,\lambda_k) \right] + g_{TM}(z,t,\lambda_k) \left[S_{TM}^f(z,t,\lambda_k) + S_{TM}^b(z,t,\lambda_k) \right] \right\}$$

$$(S8)$$

64 where η_i is the current injection efficiency, I(mA) is the injection current, e(C) is the electron charge,

L (µm) is the length of the active region, A (s⁻¹), B (cm⁻³s⁻¹), and C (cm⁻⁶s⁻¹) are the linear recombination

- 66 coefficient, the bimolecular recombination coefficient, and the Auger recombination coefficient,67 respectively.
- 68 1.4 The boundary conditions
- 69 The transmission in the FR is a passive process which induces absorption and phase delay. Since 70 the downstream signal is assumed to be TE (0°) polarized, after its rotation in the FR with an angle of 71 θ_{FR} , the upstream signal TE (e_{TE}^{b}) and TM (e_{TM}^{b}) optical fields at the EAM input become:

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$$e_{TE}^{b}(L_{SOA} + L_{EAM}, t, \lambda_{k}) = e_{TE}^{f}(L_{SOA} + L_{EAM}, t, \lambda_{k})\sqrt{T_{F}R_{2}}\cos(\theta_{FR})e^{i\Phi}$$
(S9a)

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$$e_{TM}^{b}(L_{SOA} + L_{EAM}, t, \lambda_{k}) = e_{TE}^{f}(L_{SOA} + L_{EAM}, t, \lambda_{k})\sqrt{T_{F}R_{2}}\sin(\theta_{FR})e^{i\Phi}$$
(S9b)

74 where $T_{\rm F}$ and Φ denote the round-trip transmission coefficient and the phase delay in the FR, 75 respectively. R_2 is the rear facet power reflectivity.

The powers coupled to and from the proposed device subject to the input/output port boundaryconditions:

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$$e_{TE}^{f}(0,t,\lambda_{k}) = \sqrt{R_{1}}e_{TE}^{b}(0,t,\lambda_{k}) + \sqrt{\frac{2}{n_{eff}}}\sqrt{\frac{\mu_{0}}{\varepsilon_{0}}}\alpha_{in}(1-R_{1})P_{in}(t,\lambda_{k})$$
(S10)

$$P_{TE,TM}^{out}(t,\lambda_k) = \frac{n_{eff}}{2} \sqrt{\frac{\varepsilon_0}{\mu_0}} \alpha_{out}(1-R_1) \left| e_{TE,TM}^b(0,t,\lambda_k) \right|^2$$
(S11)

80 where $P_{in}(t,\lambda_k)$ is the input power, α_{in} is the input coupling loss, α_{out} is the output coupling loss, 81 R_1 is the front facet power reflectivity. $P_{TE}^{out}(t,\lambda_k)$ and $P_{TM}^{out}(t,\lambda_k)$ are the upstream TE and TM 82 mode powers after coupling to the fiber. The total upstream output power is a summation of 83 $P_{TE}^{out}(t,\lambda_k)$ and $P_{TM}^{out}(t,\lambda_k)$.

In summary, equations (S1), (S4), (S7) and (S8), subject to the boundary conditions (S9)-(S11), are
solved for the evolution of the carrier and photon density distributions inside the PD RSOA-EAM
cavity by the numerical scheme as described in section 2.

87 2. Numerical Implementation

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88 Since the theoretical models in section 1 generally do not have an analytically solution, a 89 numerical algorithm is therefore required. As shown in Figure S1, the entire device is divided into 90 two sections: the active region including the SOA and the EAM, and the passive region including the 91 FR. The active region is divided into N segments along the light propagation direction with equal 92 length d_z , and the passive region is attached to segment N of the active region. After the light enters 93 the passive region, it will be reflected back to the active region, accompanied by the polarization 94 rotation, the power loss, and the phase delay. This effect introduced in the passive region can be 95 incorporated into the traveling wave equations by applying the transmission coefficient $T_{\rm F}$ and 96 phase delay Φ [7] as boundary conditions on the section N of the active region, as indicated in 97 equation (S9).

98 The numerical algorithm generally starts from $N(z,t=0) = N_0$ (in the SOA) and $V(z,t=0) = V_{on}$ 99 (in the EAM). The initial signal and noise optical fields are set to zero. The material gain 100 $g_{TE}(z,t=0,\lambda_k)$ in the SOA and the material loss in the EAM $\alpha_{TE,TM}^{EAM}(z,t=0)$ are calculated from (S4) 101 and (S7), respectively. The optical fields at time $t + \Delta t$ are then obtained from the analytical solution 102 of (S1) after the propagation of length d_z [2]:

$$e_{TE,TM}^{f}(z + \Delta z, t + \Delta t, \lambda_{k}) = \begin{cases} e^{\left(-\frac{j}{2}\alpha_{H}g_{TE,TM}(z,t,\lambda_{k})\right)d_{z}} \times e^{\left[\frac{1}{2}(\Gamma_{g_{TE,TM}}(z,t,\lambda_{k}) - \alpha(z))\right]d_{z}} \end{cases} e_{TE,TM}^{f}(z,t,\lambda_{k}) + d_{z}\sqrt{\frac{2}{n_{eff}}\sqrt{\frac{\mu_{0}}{\varepsilon_{0}}}\frac{\gamma hv_{k}(wd)}{d_{z}}} R_{TE,TM}^{sp}(z,t,\lambda_{k}) \cdot r_{ng}} \end{cases},$$
(S12a)

$$e_{TE,TM}^{r}(z - \Delta z, t + \Delta t, \lambda_{k}) = \begin{cases} e^{\left(-\frac{j}{2}\alpha_{H}g_{TE,TM}(z,t,\lambda_{k})\right)d_{z}} \times e^{\left[\frac{1}{2}\left(\Gamma_{g_{TE,TM}}(z,t,\lambda_{k}) - \alpha(z)\right)\right]d_{z}} \end{cases} e_{TE,TM}^{r}(z,t,\lambda_{k}) + d_{z}\sqrt{\frac{2}{n_{eff}}\sqrt{\frac{\mu_{0}}{\varepsilon_{0}}}\frac{\gamma hv_{k}(wd)}{d_{z}}} R_{TE,TM}^{sp}(z,t,\lambda_{k}) \cdot r_{ng}} \end{cases}$$
(S12b)

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105 where the last term on the right hand side represents the contribution from the spontaneous noise in step d_z , and r_{ng} is a random complex number taken from the random noise generator $x_1 e^{ix_2}$ in (S3). 106 When the optical fields hit the boundary, equations (S9) and (S10) are applied. After obtaining the 107 108 new set of optical fields, a small current step δI is added onto the SOA and the current at time 109 $t + \Delta t$ becomes: $I(z, t + \Delta t) = (eLwd/\eta_i) (AN(z, t) + BN^2(z, t) + CN^3(z, t)) + \delta I$. The carrier density 110 $N(z, t + \Delta t)$ is then calculated from the carrier rate equation (S8) by the lower order Runge–Kutta or 111 explicit Euler method. The material gain $g_{TE,TM}(z,t+\Delta t,\lambda_k)$ in the SOA and the material loss in the EAM $\alpha_{T,TM}^{EAM}(z,t+\Delta t)$ are again calculated from (S4) and (S7) with $N(z,t+\Delta t)$ and $V(z,t+\Delta t)$, 112 respectively. Next update the optical fields $e_{TE,TM}^{f,r}(z,t+2\Delta t,\lambda_k)$ through equation (S12), and then 113 $N(z,t+2\Delta t)$, $g_{TE,TM}(z,t+2\Delta t,\lambda_k)$, and $\alpha_{TE,TM}^{EAM}(z,t+2\Delta t)$ as aforementioned, then all the variables at 114 time $t + 3\Delta t$, $t + 4\Delta t$, The iteration continues until a traversal of the SOA injection current 115 116 change and the EAM voltage change is completed.



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Figure S1. Schematic diagram of the simulation setup for the polarization-discriminated RSOA EAM.

For the case of static state analysis, the time derivatives in the governing equations should become zero finally. After the current/voltage reached the maximum value, the iteration will stop if no further changes can be detected on the optical fields and the carrier densities.

- 123 In summary, the step for steady state and dynamic analysis can be concluded as follow [4]:
- 124 a) The steady state analysis procedure

125		(1) Parameters input.
126		(2) Longitudinal subdivision (in z direction).
127		(3) Variables initialization.
128		(4) Operating condition input (possible looping starts here).
129		(5) Variable scaling (physical to numerical).
130		(6) 1D- iteration loop starts.
131		(7) Solve the carrier rate equation.
132		(8) Solve the material gain equation.
133		(9) Solve the traveling wave equation.
134		(10) Go to the iteration starting point (step 6) if not converged, otherwise continue.
135		(11) Variable scaling (numerical to physical).
136		(12) Post processing for required output assembly.
137		(13) Go to step 4 for operating condition (bias, voltage, input power, or wavelength) looping,
138		until the maximum settings are reached, otherwise continue.
139		(14) Stop.
140	b)	The dynamic analysis procedure
141		(1) Parameters input.
142		(2) Longitudinal subdivision (in z direction).
143		(3) Variables initialization.
144		(4) Variable scaling (physical to numerical).
145		(5) Time domain progression starts.
146		(6) Operating condition input (read in bias/voltage/input power as function of time).
147		(7) Solve the carrier rate equation.
148		(8) Solve the gain equation.
149		(9) Solve the traveling wave equation.
150		(10) Go to the progression starting point (step 5) if the maximum time is not reached,
151		otherwise continue.
152		(11) Variable scaling (numerical to physical).
153		(12) Post processing for required output assembly.
154		(13) Stop.
155	3. Ni	umerical simulation results

156 3.1. Performance of the single-SOA section and the single-EAM section



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- 161 into the EAM section).

162 3.2. Wavelength dependence of the downstream signal erasing



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164 Figure S3. ER of the suppressed downstream signal as functions of the downstream signal165 wavelength. The rotation angle is 90°.

166 3.3. Wavelength dependence of the upstream signal at output



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168 Figure S4. Output power and Q-factor of the upstream signal as functions of the downstream signal169 wavelength.

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